INFORMATION DISCLOSURE CITATION

Atty. Docket No.	04329.3161	Serial No.	Not Yet Assigned
Applicants	Kenji KAWANO et al.		
Filing Date	October 10, 2003	Group:	Not Yet Assigned

		U.S. PA	TENT DOCUMENTS			
Examiner Initial*	Document Number	Issue Date	Name	Class	Sub Class	Filing Date If Appropriate
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34	KAWANO, K. et al., "Apparatus For Processing Substrate and Method of Processing The Same", U.S. Patent Application No. 10/026,419, filed December 26, 2001.
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	INF	ORMATION DI	SCLOSURE C	ITATION		
Atty. Docket No.	4329.3161	TE STATE OF THE ST	Appln. No. 10	0/682,419		
Applicant	Kawano et al.	SEP 23 2004 4				
Filing Date	October 10, 2003	. \$	Group: 2	812		
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Examiner Initial*	Document Number	Issue Date	Name	Class	Sub Class	Filing Date If Appropriate
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